

SEP 26 2005 By

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)	
SHIGEO KISO		:)	Examiner: Uyen Chau N. Le
Application No.: 10/781,693		;	Group Art Unit: 2876
Filed: February 20, 2004)	
For:	METHOD OF PRODUCING SUBSTRATE WITH MARK, PROGRAM FOR READING MARK, AND APPARATUS FOR READING MARK	;) ;)	September 23, 2005

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

RESPONSE TO RESTRICTION REQUIREMENT

Sir:

In response to the restriction requirement set forth in the Office Action dated September 1, 2005, Applicant provisionally elects to prosecute the Group I claims, namely Claims 1 to 18. The restriction requirement is, however, traversed.

The restriction requirement was entered pursuant to the guidelines of MPEP § 806.05(c), which permits restriction between a combination and a subcombination if two-way distinctness can be shown. Applicant respectfully submits that Groups I and II are not related as combination and subcombination. The mark-reading program and the mark-reading apparatus recited by the Group II claims are not believed to be subcombinations of the Group I method of producing a substrate with a mark.

Furthermore, Applicant respectfully submits that there would not be undue

burden in examining the two groups of claims in a single application. In particular,

MPEP § 808 makes clear that in order to require restriction between independent or distinct

inventions, reasons for insisting upon a restriction requirement, such as undue burden, must

also be shown. In the present instance, it is not believed that there would be an undue

burden in examining the claims of Groups I and II in a single application, since the two

groups of claims are not so different as would require a burden on the Examiner that is

significantly beyond that of the normal burdens of examination.

Accordingly, reconsideration and withdrawal of the restriction requirement

are respectfully requested.

Applicant's undersigned attorney may be reached in our Costa Mesa,

California office at (714) 540-8700. All correspondence should continue to be directed to

our below-listed address.

Respectfully submitted,

Damond E. Vadnais

Attorney for Applicant

Registration No. 52,310

FITZPATRICK, CELLA, HARPER & SCINTO

30 Rockefeller Plaza

New York, New York 10112-3800

Facsimile: (212) 218-2200

CA_MAIN 102318v1

- 2 -